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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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GROUP 1700

In Re Application of:

Kevin P. Martin, *et al.*

Serial No.: 09/855,972

Filed: May 15, 2001

Group Art Unit: 1763

Examiner: Hassanzadeh, Parviz

Docket No. 062002-1751

For: **METHOD AND APPARATUS FOR LOW ENERGY ELECTRON ENHANCED ETCHING OF SUBSTRATES IN AN AC OR DC PLASMA ENVIRONMENT**

FOURTH RESPONSE WITH AMENDMENTS

Assistant Commissioner
for Patents
Washington, D.C. 20231

#10C#
4/23/03
MW

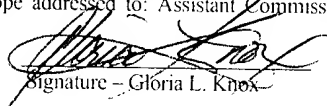
Sir:

In response to the outstanding Final Office Action mailed by the U.S. Patent and Trademark Office on January 17, 2003 (Paper No. 9), Applicants submit the following response.

It is not believed that extensions of time or fees for net addition of claims are required beyond those, which may otherwise be provided for in documents accompanying this paper. However, in the event that additional extensions of time are necessary to allow consideration of this paper, such extensions are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to Deposit Account No. 20-0778.

I hereby certify that this correspondence is being deposited with the United States Postal Service, as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on

Date: April 14, 2003


Signature - Gloria L. Knox